

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In Re Patent Application of: **Wei-Yu Su**

Serial No.: **10/040,042** Group Art Unit: **1746**
Filed: **November 7, 2001** Examiner: **Zeinab El Arini**
For: **METHOD FOR REDUCTION OF PHOTOMASK DEFECTS**
Customer No.: **08933**

PETITION FOR EXTENSION
37 C.F.R. §1.136(a)

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

Applicant requests retroactive extension of the term for response to the final rejection mailed October 3, 2006 (Paper No. 20060926), to and including the filing of the accompanying Notice of Appeal. The required fee in the amount of \$450 (large entity rate) for the requested two-month extension is being paid through Deposit Account No. 04-1679 via EFS charge authorization.

Respectfully submitted,

Date 3/5/07

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Docket No.: N1085-90003